

PATTERN

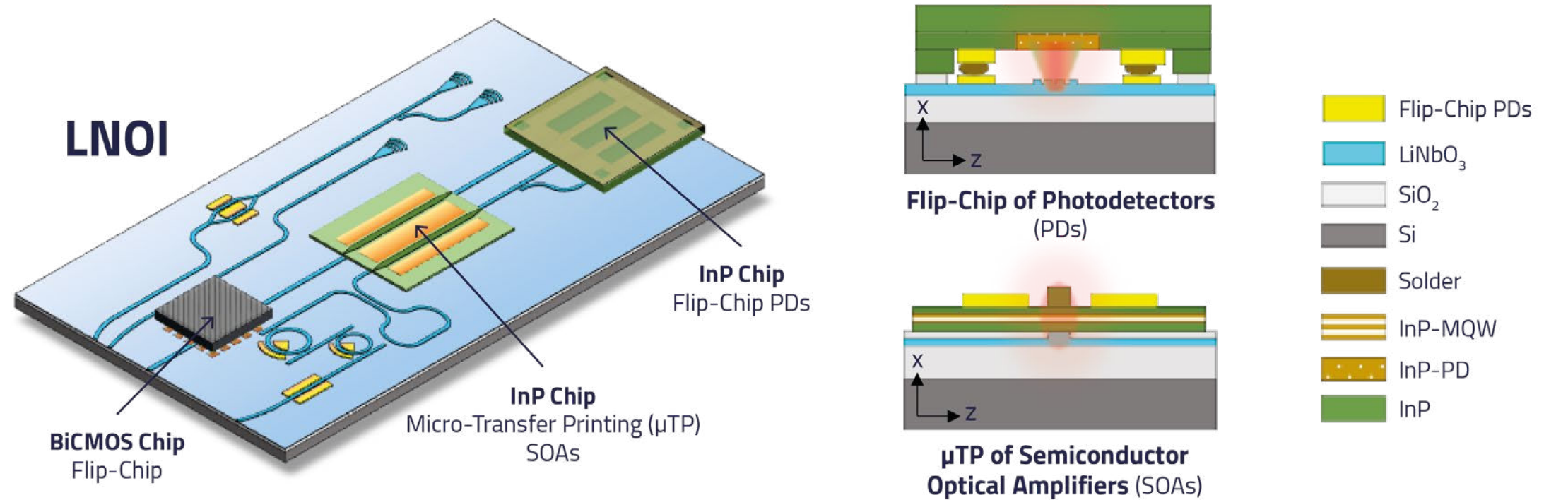
Next-generation ultra-high-speed microwave
Photonic integrATed circuitS using advancEd
hybRid iNtegration

PATTERN'S MAIN GOALS

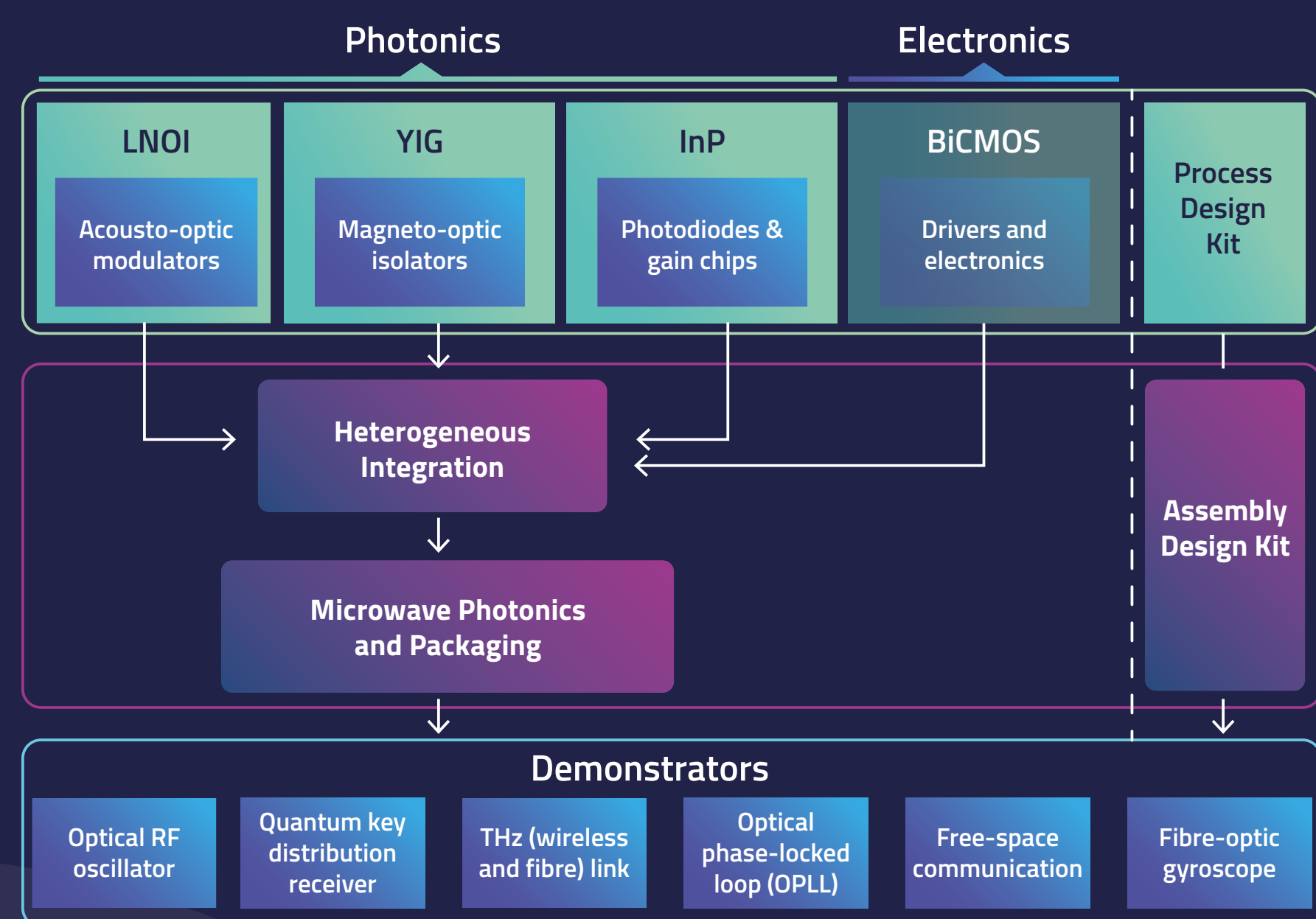
PATTERN addresses many **challenges in microwave photonics and PICs** at the same time. The main project goals are to:

- 1 Integrate all major photonic functionalities on a single hybrid PIC: light generation, transmission, manipulation and detection, as well as electronic co-integration.
- 2 Pave the way for a new generation of advanced PICs with unrivalled novel functionalities, which will serve a wide range of applications from telecom and 5G/6G to quantum, LiDAR, optical computing, and sensing technologies.

HETEROGENEOUS INTEGRATION METHODS



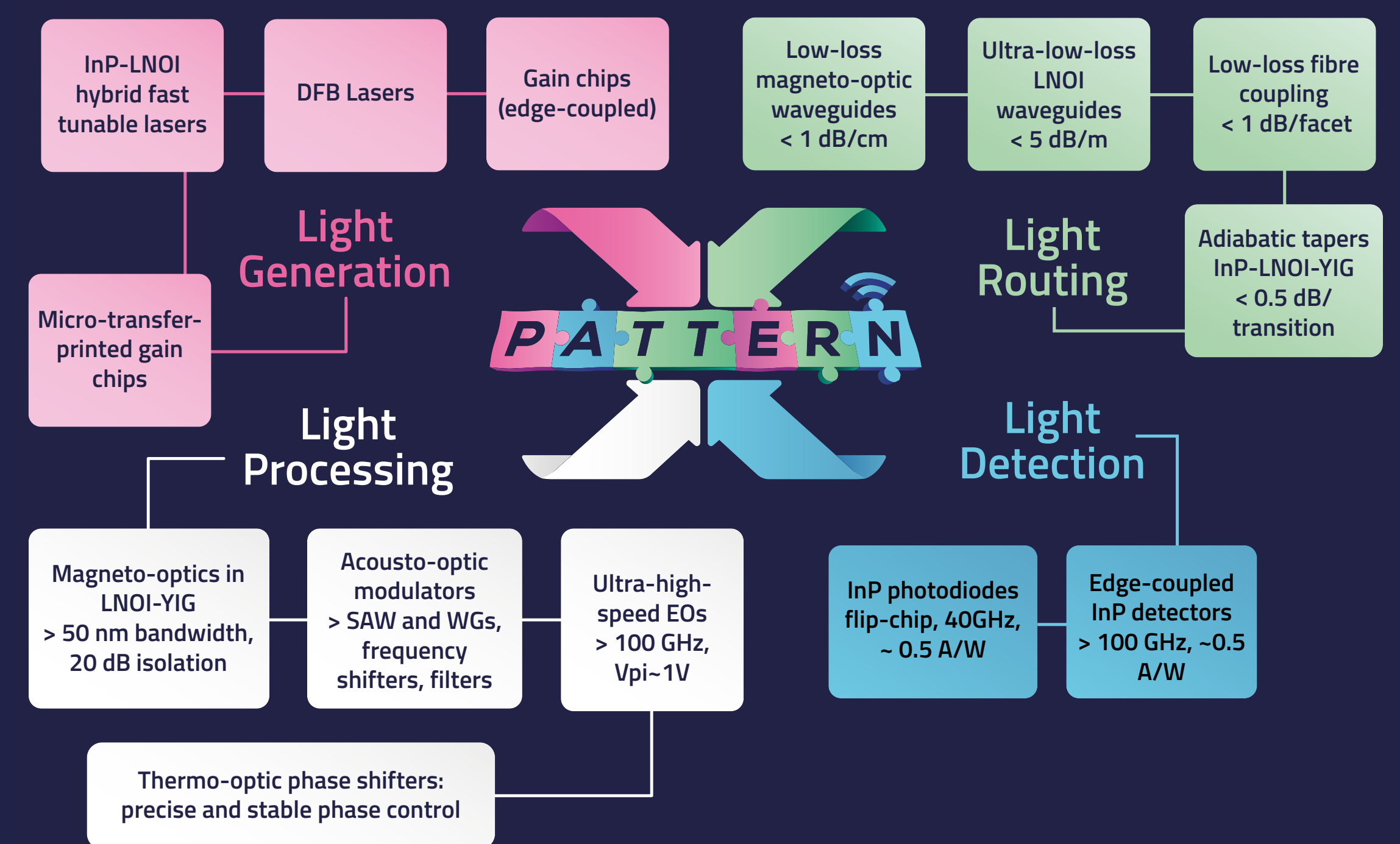
ALL FUNCTIONS ON ONE CHIP



OBJECTIVES

- 1 Develop new **advanced PIC building blocks** on an LNOI platform, enhance their fabrication quality and yield
- 2 Develop the **design flow** for the **ultra-high-speed microwave photonic systems**
- 3 Develop processes for **hybrid integration of InP and Si on top of LNOI** based on **> flip-chip bonding** (target specifications: below 1 dB / facet optical insertion losses and < 0.5 dB RF losses) **> micro-transfer printing**
- 4 Develop a **1550 nm LNOI InP fast tunable laser**
- 5 Realise six **PIC prototypes** for the end-user partners in the PATTERN consortium
- 6 Develop a platform by **cointegrating BiCMOS electronics with hybrid photonics** to facilitate ultra-high-speed electrical-optical interfacing (FIXME)

PATTERN'S ALL-IN-ONE PIC PLATFORM



Property	InP	On-chip YIG	LNOI	PATTERN Hybrid platform
Transparency window	0.9 to 2 µm	1.5 to 8 µm	0.3 to 5.5 µm	✓
Bandgap	1 eV	2.5 to 3 eV	4.9 eV	✓
Propagation losses	1.5 to 3 dB/cm	3 dB/cm	< 0.1 dB/cm	✓
Two-photon absorption	High	Very low	Very low	✓
Electro-optic coefficient	Not intrinsic	No	High (31 pm/v)	✓
Optical gain	Yes	No	No	✓
Detectors	Yes	No	No	✓
Magneto-optics (isolator)	No	Yes	No	✓
Piezo-electricity (acousto-optics)	No	No	Yes	✓
Industry status	Ramping up	Academic research	No foundry	✓

BiCMOS Integration

CONSORTIUM



PROJECT COORDINATION

Gilles Feignes, THALES
Dr Michel Despont, CSEM

EMAIL
contact@pattern-project.eu

FOLLOW US

WEBSITE
www.pattern-project.eu

COMMUNITY
in zenodo

